

Isotopic studies on the mechanism of partial oxidation of CH₄ to syngas over a Ni/Al₂O₃ catalyst

Chunyi Li ^{a,*}, Changchun Yu ^b and Shikong Shen ^b

^a College of Chemistry and Chemical Engineering, University of Petroleum, Dongying 257061, Shandong Province, PR China
E-mail: chyli@mail.hdpu.edu.cn

^b Catalytic Key Laboratory of CNPC, University of Petroleum, Changping, Beijing 102200, PR China

Received 19 March 2001; accepted 7 June 2001

An isotopic transient technique and XPS were used to investigate the mechanism of partial oxidation of CH₄ to syngas over a Ni/Al₂O₃ catalyst at atmospheric pressure and 700 °C. The experimental results show that CH₄ can decompose easily and quickly to H₂ and Ni_xC over the reduced catalyst, and Ni_xC can react rapidly with NiO from Ni oxidized by O₂ to CO or CO₂ depending on the relative concentration of Ni_xC around NiO on the catalyst surface. Both H₂ and CO are primary products in partial oxidation of CH₄. Isotopic tracing experiments prove that most of CO₂ produced during partial oxidation of CH₄ is from the surface reaction between Ni_xC and NiO, and it is impossible to mainly originate from the further oxidation of CO or the disproportionation of CO. The disproportionation of CO may happen at the experimental conditions, limited by thermodynamic equilibrium, however, the conversion of CO is very low. The pulse experiments of CH₄/O₂ and CH₄/CO₂ with stoichiometric ratio show that the rate of partial oxidation of CH₄ is faster than that of CH₄ reforming with CO₂, this implies that partial oxidation of CH₄ is unlikely to proceed *via* a combustion reforming mechanism. All the results support the direct oxidation mechanism: H₂ is from CH₄ decomposition and CO is the product of the surface reaction between Ni_xC and NiO.

KEY WORDS: methane; partial oxidation; syngas; mechanism

1. Introduction

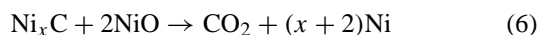
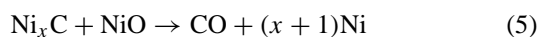
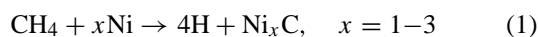
The tremendous abundance of natural gas, in which CH₄ is the principal component, is a valuable resource for mankind. It is mainly used for heating or power generation purposes. With the decrease of crude oil reserves, many chemical products or fuels will be produced with natural gas in the new century. To produce chemicals or fuels, indirect conversion of CH₄ *via* syngas should be considered firstly, for direct conversion of CH₄, *i.e.*, oxidative coupling of CH₄ has met some difficulty that cannot be overcome for a short while. Industrially, syngas is traditionally produced by steam reforming of natural gas. In recent years, partial oxidation of CH₄ has been largely studied because of its potential to reduce the cost of syngas [1].

Many supported metal catalysts, such as supported Rh, Pt, Pd, Ru, Re, Ir, Ni, Fe and Co, *etc.*, have been studied for partial oxidation of CH₄ to syngas [2–25]. Supported noble Rh catalysts exhibit excellent performances [2], but their price is rather expensive. Supported Ni catalysts have similar performance with supported Rh, and the price of Ni is far lower. So the studies on supported Ni catalyst have attracted numerous researchers [3–12].

About the mechanism of partial oxidation of CH₄, it is generally assumed to proceed according to two distinct routes: the direct oxidation mechanism and the indirect oxidation (combustion reforming) mechanism. The direct oxidation mechanism means that H₂ originates directly from the

decomposition of CH₄ and CO is from the reaction between surface oxygen and surface carbon species originating from CH₄ decomposition. In the direct oxidation mechanism, some authors [7,20,26] thought that the side product CO₂ is formed by the further oxidation of CO, and others [27,28] claimed that CO₂ is produced together with CO and is also the product of the reaction between surface oxygen and surface carbon species. In the indirect oxidation mechanism, about 25% CH₄ firstly combusts to H₂O and CO₂ with complete consumption of O₂, and then the remaining CH₄ reforms with H₂O and CO₂ to H₂ and CO [16,29,30]. Obviously, H₂ and CO are secondary products here.

Shen *et al.* [31] proposed that partial oxidation of CH₄ to syngas over a Ni/Al₂O₃ catalyst proceeds by the direct oxidation mechanism. Concretely, it is described as follows:



In the paper, the isotopic transient technique and XPS were used to investigate partial oxidation of CH₄ to syngas over the Ni/Al₂O₃ catalyst, and further pieces of evidence of the above mechanism have been given.

* To whom correspondence should be addressed.

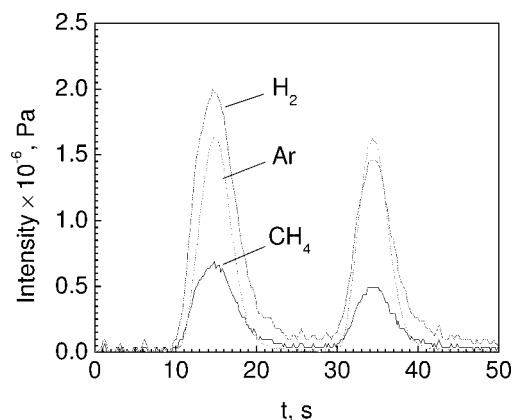


Figure 1. Pulses of 1/1 (mol) CH₄/Ar (0.39 ml for each pulse) in 30 ml/min He over the catalyst reduced by H₂ at 700 °C for 2.5 h.

2. Experimental

The 8 mol% Ni/Al₂O₃ catalyst was prepared by coprecipitation and the preparing steps have been described in detail elsewhere [32]. The BET surface area and the dispersion of Ni on Al₂O₃ measured by ASAP2010 are 280 m²/g and about 5%, respectively. The granule range is 0.3–0.45 mm.

The isotopic transient apparatus has been introduced in [31]. 30 mg catalyst was placed in the middle of the quartz reactor with inside diameter of 5.5 mm, and the other space of the reactor was filled with 0.45–0.9 mm quartz sand to shorten the residence time of the reactants and products to quicken the response speed of transient. The height of the catalyst bed was about 2 mm. An AI-FUZZY temperature controller combined with a K thermocouple controlled the reactor temperature. The products were detected by an on-line AMETEK quadrupole mass spectrometer with eight channels and the minimum dwell time 3 ms. All the experiments were carried out at atmospheric pressure and 700 °C. The total flow rate at the inlet of the reactor was 30 ml/min. Both ¹³CO (91.7 mol%) and ¹⁸O₂ (92.9 mol%) were purchased from Merck Frosst Canada Company.

The X-ray photoelectron spectra of the carbon-deposited catalyst were recorded in a VG Scientific ESCALAB 210 electron spectrometer, equipped with a Mg K_α X-ray source and a hemispherical electron analyzer. The peak positions are relative to the binding energy of Al 2p at 74.6 eV.

3. Results

3.1. Decomposition of CH₄ over the reduced catalyst

The catalyst was reduced with pure H₂ for 2.5 h at 700 °C, then 1/1 (mol) CH₄/Ar pulses were conducted in pure He, where Ar as the tracer was used to indicate the decomposing rate of CH₄. In figure 1, H₂ from CH₄ decomposition appears simultaneously with inert tracer Ar after the pulses, which illuminates that the rate of CH₄ decomposition is fast; otherwise the response of H₂ must have some delay compared to that of Ar, for inert gas Ar does not adsorb on the

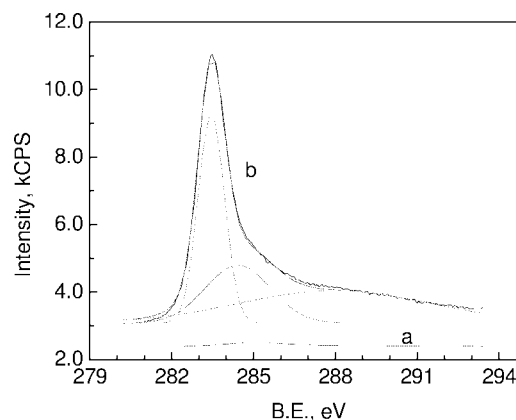


Figure 2. XPS C 1s spectra for the catalysts. (a) The reduced catalyst and (b) the carbon-deposited catalyst.

surface of the catalyst, and its residence time may be seen as zero. The formation of H₂, however, is a complex process including CH₄ adsorbing, decomposing, and hydrogen combining to H₂ and its desorbing. If any one of these steps is slow, then H₂ cannot possibly respond with Ar at the same time.

The catalyst was firstly reduced under the same conditions, and then we switched the gas from H₂ to CH₄. After the switch, CH₄ decomposed immediately to produce H₂. When CH₄ finished decomposing and no H₂ was produced, we switched the atmosphere to pure Ar at once and cooled the reactor in an ice/water bath. Thus we prepared the carbon-deposited catalyst. The carbon-deposited catalyst and only reduced catalyst were then characterized by XPS. The results are shown in figure 2. Between 280 and 288 eV, the spectrum of the carbon-deposited catalyst has two carbon peaks compared to that of the reduced catalyst. The one corresponding to 283.5 eV can be ascribed to metal carbides Ni_xC ($x = 1-3$) [33,34], and we call the other corresponding to 284.5 eV transition carbon.

In TPO of the carbon-deposited catalyst, only CO, CO₂ and no H₂O were detected. This means that CH₄ can decompose thoroughly to hydrogen and carbon over the catalyst [35]. As for whether CH₄ decomposes step by step in the sequence CH₃ → CH₂ → CH → C or not, no direct evidence was obtained in the experiments. Furthermore, metal carbides are easy to be oxidized and transition carbon is more difficult [35]. And metal carbides can convert to transition carbon at high temperature [35,36]. These results show that the carbides from CH₄ decomposition initially may be Ni_xC. Therefore, the decomposition of CH₄ over the Ni/Al₂O₃ catalyst can be described with reactions (1) and (2) in section 1.

3.2. Decomposition of CH₄ over the oxidized catalyst

In [32], the transient experiment from O₂/Ar to CH₄ shows that only small amounts of CO₂ and CO are detected and CH₄ does not decompose just after the switch. After 3–4 s inducing period during which nearly no product is produced and metal Ni sites, which are necessary for CH₄

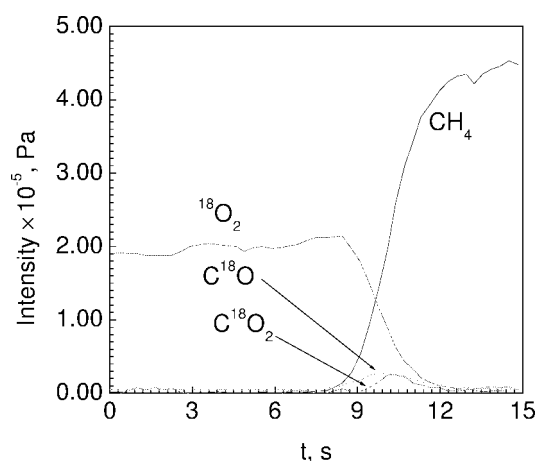


Figure 3. Transient switch from 1/2 (mol) $^{18}\text{O}_2/\text{Ar}$ to CH_4 over the catalyst oxidized in 1/2 (mol) O_2/He at 700°C for 1 h.

decomposing, are formed on the oxidized catalyst surface, CH_4 starts to decompose with the formation of H_2 , and a great deal of CO and CO_2 are produced simultaneously. The CO and CO_2 produced just after the switch are due to the reaction between CH_4 and adsorbed oxygen for we have excluded the possibility of gas phase reaction between CH_4 and O_2 at the experimental conditions. The CO and CO_2 produced with CH_4 decomposing together are from the reaction between Ni_xC and NiO (reactions (5) and (6)). Here, isotopic experiments were conducted to prove these viewpoints further.

The catalyst was firstly oxidized in 1/2 (mol) O_2/He for 1 h and 1/2 (mol) $^{18}\text{O}_2/\text{Ar}$ for 1 min in turn at 700°C , then the switch from $^{18}\text{O}_2/\text{Ar}$ to pure CH_4 was performed (figure 3). In the figure, only a little C^{18}O and C^{18}O_2 appear and CH_4 does not decompose. The amount of adsorbed oxygen species on the catalyst surface is very small and CH_4 is far surplus, but there is C^{18}O_2 produced, which proves that CH_4 is easy to be oxidized by adsorbed oxygen and the oxidation is nonselective. No CO or CO_2 is detected here. This means adsorbed oxygen can exchange with gas phase $^{18}\text{O}_2$ rapidly.

Before switching to CH_4 , if the catalyst bed was swept with pure He for several minutes, the result was completely different (figure 4). For the formation of metal Ni sites during the sweeping [32], CH_4 decomposes immediately after the switch, and H_2 , CO and CO_2 are produced. The intensity of CO approaches that of CO_2 at the very beginning of the switch, for the amount of Ni_xC from CH_4 decomposition is relatively small compared to that of NiO on the catalyst surface. With the increase of the quantity of Ni_xC , the difference between the intensity of CO and that of CO_2 is enlarged. This proves that to produce CO or CO_2 is dependent on the relative concentration of Ni_xC around NiO on the catalyst surface. Obviously, the reaction between Ni_xC and NiO , different from that between CH_4 and adsorbed oxygen, is not only fast, but also more selective at the condition of deficient O_2 . Furthermore, that no C^{18}O or C^{18}O_2 is detected in figure 4 shows that the $^{18}\text{O}_2$ in gas phase cannot exchange with the oxygen in NiO rapidly.

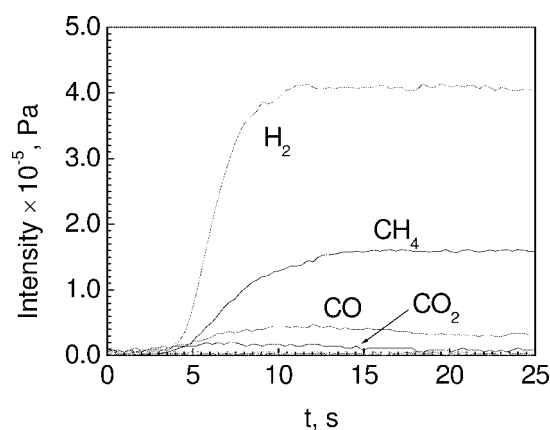


Figure 4. Transient switch from He to CH_4 after oxidation of the catalyst with 1/2 (mol) O_2/He for 1 h and 1/2 (mol) $^{18}\text{O}_2/\text{Ar}$ for 1 min in turn.

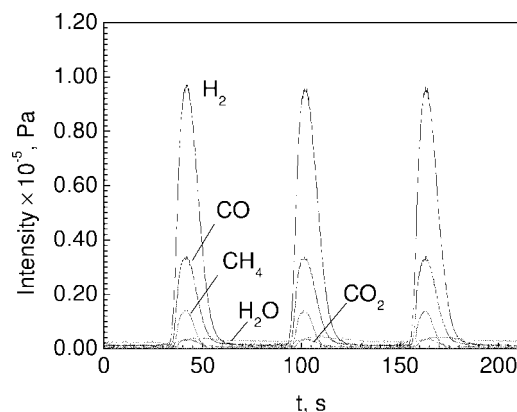


Figure 5. Pulse reaction of 2/1 (mol) CH_4/O_2 (5 ml) in 30 ml/min He over the catalyst reduced by H_2 for 2 h at 700°C .

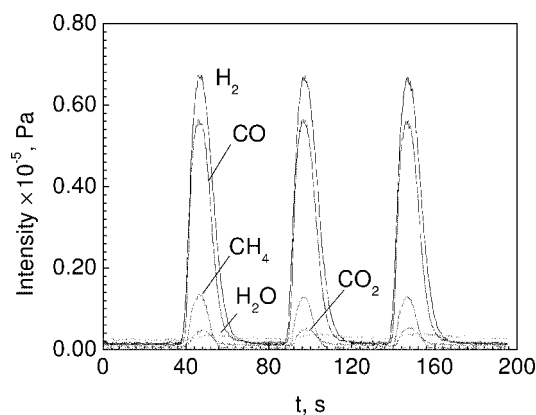


Figure 6. Pulse reaction of 1/1 (mol) CH_4/CO_2 (5 ml) in 30 ml/min He over the catalyst reduced by H_2 for 2 h at 700°C .

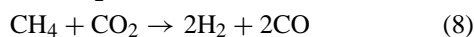
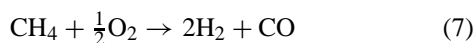
3.3. Pulses of 2/1 (mol) CH_4/O_2 and 1/1 (mol) CH_4/CO_2

The pulses of 2/1 (mol) CH_4/O_2 and 1/1 (mol) CH_4/CO_2 were conducted in 30 ml/min pure He over the reduced catalyst at 700°C to investigate the rates of partial oxidation and reforming. The pulse quantity was 5 ml and the results are shown in figures 5 and 6, respectively. In figure 5, H_2 and CO are the main products, and H_2O and CO_2 produced

are only a little. In figure 6, H₂ and CO are also the main products.

Partial oxidation of CH₄ is a warm exothermic reaction, and CH₄ reforming with CO₂ is an endothermic reaction. Reaction rate, however, is sensitive to temperature. The reason to use the pulse reaction method is to avoid the influence of thermal effect. Because the amount of reactants pulsed is small and the contact time with the catalyst bed is very short – less than 10⁻² s, for the height of the catalyst bed is only about 2 mm – the reaction heat released or adsorbed and its influence on the temperature of the catalyst bed can be neglected.

Both in partial oxidation of CH₄ and in CH₄ reforming with CO₂, H₂ originates from CH₄,



So, in figures 5 and 6, we use the ratio of the maximum peak intensities of the H₂ produced and the remaining CH₄ to represent the conversion of CH₄. In figure 5, it is about 6.3. In figure 6, however, it is only about 4.8. Therefore, although the reaction conditions are the same, the conversion of CH₄ in partial oxidation is remarkably higher than that in CH₄ reforming with CO₂. Furthermore, O₂ is consumed completely in partial oxidation, while CO₂ is not in CH₄ reforming. Obviously, the rate of partial oxidation of CH₄ is faster than that of CH₄ reforming with CO₂.

3.4. Transient responses from He to 10/5/1 (mol) CH₄/O₂/Ar

Over the reduced catalyst, the transient switch from pure He to 10/5/1 (mol) CH₄/O₂/Ar with the same flow rate was performed at 700 °C and the responses were normalized with the formula

$$F = \frac{y - y_0}{y_\infty - y_0}, \quad (9)$$

where F is the normalized intensity and y_0 , y and y_∞ are the intensity at the beginning, at any time and at the end of response, respectively. The normalized results are shown in figure 7. After the switch, the products H₂ and CO appear simultaneously with the inert tracer Ar, and their normalized responses are intertwined together. This indicates that the producing rates of H₂ and CO are very fast. If it is supposed that H₂ and CO are secondary products from the reforming reactions of the remaining CH₄ with CO₂ and H₂O, combustion products of CH₄ with O₂, it is impossible for H₂ and CO to response together with Ar, for reforming reactions, especially CH₄/H₂O reforming, are slower than partial oxidation of CH₄ [27,37].

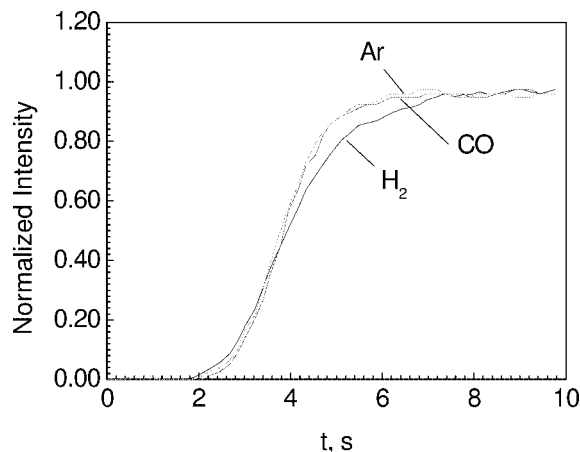


Figure 7. Normalized responses after the transient switch from 30 ml/min He to 10/5/1 (mol) CH₄/O₂/Ar with the same flow rate over the catalyst reduced by H₂ for 2 h at 700 °C.

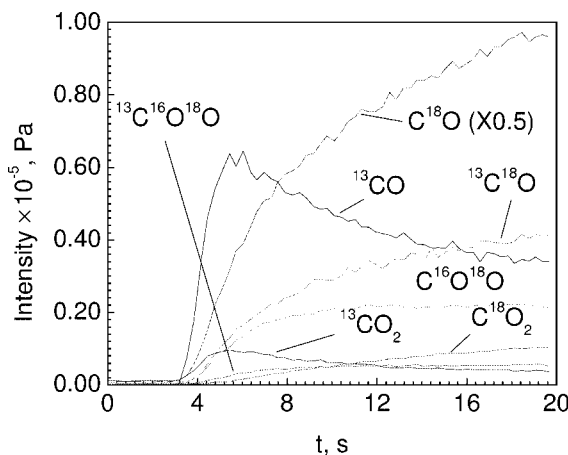


Figure 8. Transient responses from 2/1/1 (mol) CH₄/O₂/He to 2/1/2/1/1 (mol) CH₄/¹⁸O₂/H₂/¹³O/Ar at 700 °C.

3.5. Isotopic transient responses from 2/1/1 (mol) CH₄/O₂/He to 2/1/2/1/1 (mol) CH₄/¹⁸O₂/H₂/¹³O/Ar and from 2/1/1 (mol) CH₄/O₂/He to CH₄/¹⁸O₂/Ar

After CH₄/O₂/He had reacted for 20 min over the catalyst pre-reduced at 700 °C in pure H₂, a transient switch to CH₄/¹⁸O₂/H₂/¹³CO/Ar was conducted. The results are shown in figure 8. Adding of certain amounts of ¹³CO to the reactants is to investigate the disproportionation of CO during partial oxidation of methane. The products after the switch include C¹⁸O, C¹⁶O¹⁸O, CO, C¹⁸O₂, ¹³C¹⁸O, ¹³CO₂ and ¹³C¹⁶O¹⁸O. The selectivity to total carbon monoxide is 88%.

If CO₂ originates mainly from the disproportionation of CO during partial oxidation of methane, there should be more ¹³CO₂ after the switch. But in figure 8, the maximum content of ¹³CO₂ in total carbon oxides is only about 1.5%. So CO₂ must mainly originate from other reactions. There is about 12% ¹³C¹⁸O at 20 s in figure 8. This shows that the disproportionation of ¹³CO happens and is very fast

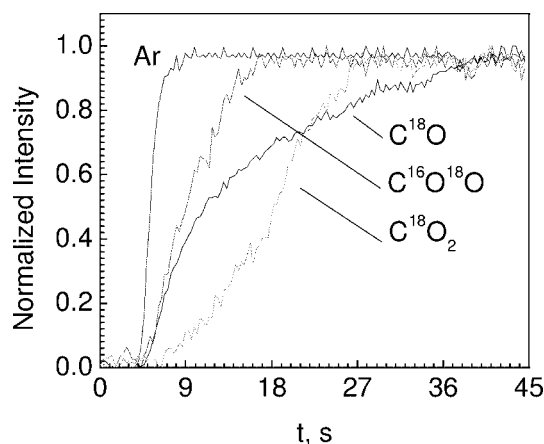
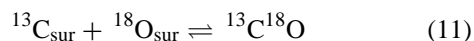
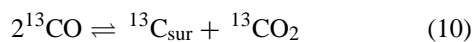


Figure 9. Transient responses of the switch from 2/1/1 (mol) CH₄/O₂/He to CH₄/¹⁸O₂/Ar with the same ratio in steady state at 700 °C.

for ¹³C¹⁸O can only be formed from ¹³CO by



However, disproportionation of CO is limited by thermodynamic equilibrium. As though the disproportionation of CO is not the main origin of CO₂, by the reaction, C in gas phase can exchange with surface C.

If CO₂ is mainly from the further oxidation of CO, there should be more ¹³C¹⁸O after the switch. In fact, the maximum content of ¹³C¹⁸O is only 1.2%. So further oxidation of CO is impossible to be the main origin of CO₂.

In figure 8, most carbon dioxide is CO¹⁸O at the beginning of the switch, and C¹⁸O₂ substitutes CO¹⁸O little by little with time on stream. After the switch, O can only be from the catalyst surface, and further oxidation of CO is not easy to occur under the experimental conditions. So CO¹⁸O is from surface reaction among Ni_xC, NiO and Ni¹⁸O. With the decrease of NiO and the increase of Ni¹⁸O, the possibility to CO¹⁸O drops and the possibility to C¹⁸O₂ rises gradually. So the intensity of C¹⁸O₂ increases little by little and the intensity of CO¹⁸O firstly increases and then decreases after the switch. CO¹⁸O and C¹⁸O₂ are the two most abundant carbon dioxides. Therefore, surface reaction between Ni_xC and NiO is the main origin of CO₂.

The steady-state isotopic transient experiment supports the above conclusions, too. At 700 °C after CH₄/O₂/He had reacted for 20 min over the reduced catalyst, a steady-state transient switch was conducted from CH₄/O₂/He to CH₄/¹⁸O₂/Ar, where He and Ar were the tracers. The input responses of Ar, C¹⁸O, C¹⁸O₂ and CO¹⁸O were normalized with the formula (9). The results are shown in figure 9. Ar, C¹⁸O and CO¹⁸O begin to response nearly at the same time after the switch, however, the response of C¹⁸O₂ has some delay compared to that of Ar, C¹⁸O and CO¹⁸O. At the very beginning just after the switch, there is relatively more NiO and less Ni¹⁸O on the catalyst surface, so the possibility to produce CO¹⁸O is higher than that to produce C¹⁸O₂. With the increase of surface ¹⁸O, the possibility to produce C¹⁸O₂

increases gradually, but the possibility to CO¹⁸O decreases. So the intensity of CO¹⁸O firstly increases then decreases, and the response of C¹⁸O₂ has some delay compared to the inert tracer Ar.

The above results show that CO₂ mainly originates from the surface reaction between Ni_xC and NiO, not from the disproportionation of CO or the further oxidation of CO.

4. Discussion

There are still arguments about the mechanism of partial oxidation of CH₄ over supported metal catalysts. Some authors thought that the reaction proceeds by a direct oxidation mechanism, and others insisted that a combustion reforming mechanism is reasonable. Perhaps, the mechanism is different over different catalysts or under different reaction conditions. Based on the above experimental results, however, the possibility that the reaction proceeds by a direct oxidation mechanism is larger than that by a combustion reforming mechanism over the Ni/Al₂O₃ catalyst under the experimental conditions.

The decomposition of CH₄ is the precondition for the direct oxidation mechanism. If CH₄ cannot decompose quickly, the conversion of CH₄ and the selectivities to H₂ and CO must be affected. In figure 1, we can see clearly that CH₄ does decompose rapidly over the reduced catalyst. Combustion of CH₄ and O₂ is the precondition for the combustion reforming mechanism. It is the same that this step must proceed quickly, otherwise the conversion and selectivities will be limited. According to Dissanayake's point of view [29], the catalyst bed consists of three different regions from the top down. The first of these, contacting the initial CH₄/O₂ feed mixture, is NiAl₂O₄, which has only moderate activity for complete oxidation of CH₄ to H₂O and CO₂. The second region is NiO/Al₂O₃, over which complete oxidation of CH₄ to H₂O and CO₂ occurs. The third portion consists of reduced Ni/Al₂O₃, over which reforming reactions of the remaining CH₄ with H₂O and CO₂ to H₂ and CO happen. Surely, NiO/Al₂O₃ catalyst can catalyze the combustion reaction. When 2/1 (mol) CH₄/O₂ gas flow passes through the oxidized catalyst under the experimental conditions, the conversions of CH₄ and O₂ are all very low [32]. Obviously, the subsequent reforming reactions of the remaining CH₄ with CO₂ and H₂O cannot proceed with high CH₄ conversion, even though there is reduced Ni/Al₂O₃ below the oxidized. However, when the catalyst is reduced, the reaction can proceed with about 90% CH₄ conversion, complete consumption of O₂, and more than 90% syngas selectivity. The Ni/Al₂O₃ catalyst must be reduced for CH₄ cannot decompose over NiO. If the catalyst is oxidized, partial oxidation of CH₄ will not be able to proceed normally at 700 °C [32].

If partial oxidation of CH₄ goes by combustion reforming mechanism and the first step of combustion can proceed thoroughly, the second step, the remaining CH₄ reforming with H₂O and CO₂ from the first step must proceed simultaneously. Otherwise, the selectivity to H₂ or CO will be

lowered for H₂O or CO₂ cannot convert to H₂ or CO effectively. That is to say, the rates for CH₄ reforming with H₂O and CO₂ should be fast, at least, they should not be slower than the overall rate of partial oxidation. Tang *et al.* [27] pulsed 2/1 (mol) CH₄/O₂ and 1/1 (mol) CH₄/CO₂ at 650 °C, the conversion of CH₄ in the former pulse is more than 60%, and that in the latter is only 26.2%. Our results in section 3.3 are consistent to that. So the rate of partial oxidation is faster than that of CH₄ reforming with CO₂ at 700 °C. Furthermore, if combustion reforming is the real mechanism of partial oxidation, adding steam in the reactant will promote the second step, consequently, the conversion of CH₄ and the selectivity to H₂ will be improved. However, Zhang [38] found that the conversion and selectivity do not change when adding steam into the reactor during partial oxidation of CH₄. Vermeiren *et al.* [37] also proved that partial oxidation of CH₄ is 13 times faster than the reforming reaction of CH₄ with H₂O. These all indicate that partial oxidation of CH₄ to syngas is impossible to proceed by the combustion reforming mechanism with very short contacting time.

Moreover, partial oxidation of CH₄ to syngas is a fast and exothermic reaction, so the temperature of the catalyst bed is unlikely to be uniform. In our experiments, about 90% CH₄ conversion can be achieved although the height of the catalyst bed is only 2 mm. That is to say, even though the catalyst bed is higher, maybe most of the reaction takes place only within the very thin bed nearby the inlet of the catalyst bed. The heat released causes the temperature of the part of the catalyst bed increase, thus, the temperature gradient is formed along the axis of the reactor. If combustion reforming is the real mechanism, and the higher temperature within the inlet region is caused by the combustion of CH₄ with total O₂, the strong endothermic reforming reactions of the remaining CH₄ with H₂O and CO₂ will be impossible to proceed rapidly over the below catalyst bed as the temperature is low.

During partial oxidation of CH₄, there is a little carbon species on the catalyst surface that can participate in the reaction under the experimental conditions, which is favorable for keeping the catalyst reduced. From the point of view of the reaction between Ni_xC and NiO, some active carbon species existing on the catalyst surface may mean reaction (5) is the rate-limiting step of partial oxidation of CH₄ to syngas. For Ni_xC can convert slowly to graphite, which is inert and affects the activity of the catalyst under the experimental conditions, *via* transition carbon at high temperature [35], reducing the activity of the catalyst for CH₄ decomposition appropriately and promoting the reaction between Ni_xC and NiO by adjusting the composition of the catalyst may be favorable for improving the performance of anti-carbon deposition.

5. Conclusions

At atmospheric pressure and 700 °C, CH₄ decomposes easily and quickly to H₂ and Ni_xC over the reduced cata-

lyst, and Ni_xC can react rapidly with NiO from Ni oxidized by O₂ to CO or CO₂ depending on the relative concentration of Ni_xC around NiO on the catalyst surface. Both H₂ and CO are primary products in partial oxidation of CH₄. CO₂ is also mainly from the surface reaction between Ni_xC and NiO, not from the combustion of CH₄ with O₂, and the contribution of the disproportionation of CO or the further oxidation of CO to CO₂ can nearly be neglected. The rate of partial oxidation of CH₄ is faster than that of the reforming of CH₄ with CO₂ under the same conditions. All of these support the direct oxidation mechanism described as reactions (1)–(6). Reaction (5) may be the rate-limiting step for partial oxidation of CH₄ to syngas.

Acknowledgement

This research was supported by the National Natural Science Foundation of China (Issue No. 29673027) and China Natural Gas & Petroleum Corporation.

References

- [1] A.G. Ruiz, P.F. Aparicio, M.B.B. Baeza and I.R. Ramos, *Catal. Today* 46 (1998) 99.
- [2] D.A. Hickman and L.D. Schmidt, *J. Catal.* 138 (1992) 267.
- [3] M. Prettre, C.H. Bichner and M. Perrin, *Trans. Faraday Soc.* 43 (1946) 335.
- [4] T. Hayakawa, A.G. Anderson, M. Shimizu and K. Suzuki, *Catal. Lett.* 22 (1993) 307.
- [5] Y. Lu, C. Deng, X.J. Ding and S.K. Shen, *Chinese J. Catal.* 17 (1996) 28.
- [6] V.R. Choudhary, V.H. Rane and A.M. Rajput, *Catal. Lett.* 22 (1993) 289.
- [7] V.R. Choudhary, A.M. Rajput and B. Prabhakar, *J. Catal.* 139 (1993) 326.
- [8] V.R. Choudhary, A.M. Rajput and B. Prabhakar, *Catal. Lett.* 32 (1995) 391.
- [9] V.R. Choudhary, V.H. Rane and A.M. Rajput, *Catal. Lett.* 16 (1992) 269.
- [10] V.R. Choudhary, S.D. Sansare and A.S. Maman, *Appl. Catal.* 89 (1992) 90.
- [11] V.R. Choudhary, A.M. Rajput and V.H. Rane, *J. Phys. Chem.* 96 (1992) 8686.
- [12] A. Slagtern, H.M. Swaan, U. Olsbye, I.M. Dahl and C. Mirodatos, *Catal. Today* 46 (1998) 107.
- [13] A.K. Bhattacharya, J.A. Breach, S. Chand, D.K. Ghorai, A. Hargridge, J. Keary and K.K. Mallick, *Appl. Catal.* 80 (1992) L1.
- [14] P.E. Marti, M. Maciejewski and A. Baiker, *J. Catal.* 139 (1993) 494.
- [15] A. Slagterm and U. Olsbye, *Appl. Catal.* 110 (1994) 99.
- [16] A.T. Ashcroft, A.K. Cheetham, J.S. Foord, M.L.H. Green, C.P. Grey, A.J. Murrell and P.D.F. Vernon, *Nature* 344 (1990) 319.
- [17] P.D.F. Vernon, M.L.H. Green, A.K. Cheetham and A.T. Ashcroft, *Catal. Lett.* 6 (1990) 181.
- [18] P.D.F. Vernon, M.L.H. Green, A.K. Cheetham and A.T. Ashcroft, *Catal. Today* 13 (1992) 417.
- [19] D.A. Hickman and L.D. Schmidt, *J. Catal.* 138 (1992) 267.
- [20] D.A. Hickman and L.D. Schmidt, *Science* 259 (1993) 343.
- [21] D.A. Hickman, E.A. Hauptfear and L.D. Schmidt, *Catal. Lett.* 17 (1993) 223.
- [22] D.A. Hickman and L.D. Schmidt, *AIChE J.* 39 (1993) 1164.
- [23] S.S. Bharadwaj and L.D. Schmidt, *J. Catal.* 146 (1994) 11.
- [24] A.G. Dietz and L.D. Schmidt, *Catal. Lett.* 33 (1995) 15.

- [25] P. Torniainen, X. Chu and L.D. Schmidt, *J. Catal.* 146 (1994) 1.
- [26] E.P.J. Mallens, J.H.B.J. Hoebink and G.B. Marin, *J. Catal.* 167 (1997) 43.
- [27] S. Tang, J. Lin and K.L. Tan, *Catal. Lett.* 55 (1998) 83.
- [28] Y. Matsumura and J.B. Moffat, *Catal. Lett.* 24 (1994) 59.
- [29] D. Dissanayake, M.P. Rosynek, K.C.C. Kharas and J.H. Lunsford, *J. Catal.* 132 (1991) 117.
- [30] F.V. Looij, J.C.V. Giezen, E.R. Stobbe and J.W. Geus, *Catal. Today* 21 (1994) 495.
- [31] S.K. Shen, C.Y. Li and C.C. Yu, *Stud. Surf. Sci. Catal.* 119 (1998) 765.
- [32] C.Y. Li, C.C. Yu and S.K. Shen, *Catal. Lett.* 67 (2000) 139.
- [33] B.M. Weckhuysen, M.P. Rosynek and J.H. Lunsford, *Catal. Lett.* 52 (1998) 31.
- [34] C.C. Yu and S.K. Shen, *Chin. J. Chem. Phys.* 10 (1997) 233.
- [35] C.Y. Li, C.C. Yu and S.K. Shen, *Chin. J. Catal.*, accepted.
- [36] C.Y. Li, C.C. Yu and S.K. Shen, *Acta Chim.* 58 (2000) 1188.
- [37] W.J.M. Vermeiren, E. Blomsma and P.A. Jacobs, *Catal. Today* 13 (1992) 427.
- [38] Z.B. Zhang, Ph.D. Dissertation, University of Petroleum, Beijing (1999).